## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re th	ne Application of:	)	
	Yuichiro Nakamura et al.	)	Examiner:
Applic	eation No.:	)	Group Art Unit:
Corres	ponding International Filing No.: PCT/JP2005/002221	)	
Filed:	Herewith	)	
For:	Co-Cr-Pt-B ALLOY SPUTTERING TARGET	)	

Mail Stop PCT Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## VERIFICATION OF TRANSLATION

Sir:

I, Isamu Ogoshi, having been warned that willful false statements and the like are punishable by fine or imprisonment or both, under section 1001 of Title 18 of the United States Code, and may jeopardize the validity of the above-captioned application and any patent issuing thereon, declare:

- I am a patent attorney authorized to practice law in Japan and am engaged in
  the practice of law with OGOSHI International Patent Office at Toranomon 9 Mori Bldg. 3F,
  2-2, Atago 1-Chome, Minato-ku, Tokyo 105-0002, Japan.
  - I am fluent in the Japanese and English Languages.

(3) I have reviewed the attached translation, and certify that it is an accurate English translation of the Japanese language international application of Yuichiro Nakamura and Akira Hisano filed on February 15, 2005 and given International Application No. PCT/JP2005/002221.

(4) All of the statements made herein of my own knowledge are true and all statements made herein on information and belief are believed to be true.

Soptember (4,2006 Same Ogosla)

Date Isamu Ogoshi